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BLACK PLATED SUBSTRATE

Title (de)
SCHWARZPLATTIERTES SUBSTRAT

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SUBSTRAT PLAQUÉ NOIR

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Abstract (en)
[origin: WO2022123019A1] The present invention relates to a method for electrodepositing a dark chromium layer on a substrate and a substrate having at least one side fully covered with a dark chromium layer. The method includes utilizing an aqueous trivalent chromium electroplating bath comprising colloidal particles and a step of treating the substrate with a rinse liquid having a temperature of 50°C or more.

IPC 8 full level
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